

Experimental and Theoretical Studies of Cloxacillin on the Corrosion of Mild steel in 1M H₂SO₄

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Abstract

Corrosion behaviour of mild steel in 1M Sulphuric acid with Cloxacillin as corrosion inhibitor has been studied by using weight loss, Potentiodynamic polarization, Electrochemical impedance spectroscopy, Hydrogen permeation and diffuse reflectance spectroscopic studies. All these techniques reveal that inhibition efficiency increases with the increase in the concentration of inhibitor. Scanning electron microscopy (SEM) was carried out to characterize the surface morphology of the metal. Polarization studies indicated that inhibitor behaved as cathodic inhibitor. Diffuse reflectance spectroscopy confirmed the adsorption of inhibitor on the mild steel surface obeying Langmuir adsorption isotherm. A chemoffice 3D simulation technique was used to run the quantum mechanical analysis and established correlations between different types of descriptors and measured corrosion inhibition efficiency for inhibitor. The quantum chemical analysis substantiates the inhibition efficiencies of the compound determined by electrochemical methods.

Keywords: Mild Steel, Corrosion Inhibition, Cloxacillin, Adsorption Isotherm, Quantum chemical studies.

Introduction

Mild steel is an important category of metals due to its excellent mechanical properties. It is extensively used under different conditions in chemical and allied industries in handling acidic, alkaline and salt solutions. Mild is used in industries as pipelines for petroleum industries, storage tanks, reaction vessel and chemical batteries [1]. Acid

solutions are widely used in many industrial processes. Acids are used for acid cleaning, pickling and descaling due to their chemical properties [2–5]. Acids cause damage to the substrate, because of their corrosive nature. Several methods were used to decrease the corrosion of metals in acidic medium, but the use of inhibitors is most commonly used [6–10].

Organic compounds are widely used as corrosion inhibitors for mild steel in acidic media [11–16]. The rate of corrosion decreases by adsorption of organic inhibitors on the metal surface. The inhibitors block the active sites by displacing water molecules and form a compact barrier film on the metal surface. The most of the organic inhibitors are toxic, highly expensive and non environment friendly. Research activities in recent times are geared towards developing the cheap, non-toxic drugs as environment friendly corrosion inhibitors [17–21].

The aim of this work is to investigate the corrosion protection efficiency of cloxacillin for mild steel corrosion in 1M H₂SO₄. We came to know that exceedingly few reports are available by using this compound as corrosion inhibitor in 0.1M H₂SO₄ [22–24]. No concrete report is available for the use these compounds as corrosion inhibitors in 1M H₂SO₄. From the literature the higher concentration of H₂SO₄ acts as pickling solution for mild steel for electroplating, battery electrodes using sulphur containing organic compounds. Use of this inhibitor in 1M H₂SO₄ will reduce the metal loss in acid medium. The compound is large enough and sufficiently planar to block more surface area on the mild steel. The inhibition efficiency was calculated using weight loss measurement, potentiodynamic polarization studies, impedance techniques, hydrogen permeation studies and diffuse reflectance methods. A definite correlation exists between different types of descriptors and measured corrosion inhibition efficiency for cloxacillin using chemical and electrochemical techniques.

2. Experimental Details

2.1. Materials

Mild steel specimens of size 1x4 cm² were used for weight loss and electrochemical studies. The aggressive solution of 1M H₂SO₄ (AR Grade) was used for all the studies. The antibiotic namely cloxacillin was purchased from the corresponding manufacturing company. The structure of the antibiotic is given in the figure 1. Electrochemical experiments were performed using a three electrode cell assembly with mild steel samples as working electrode, 4cm² area of platinum as counter electrode and Hg/Hg₂SO₄/1M H₂SO₄

as the reference electrode. The surfaces of corroded and corrosion inhibited mild steel specimens were examined by diffuse reflectance studies in the region 200–700 nm using U-3400 spectrometer (UV-VIS-NIR Spectrometer, Hitachi, Japan).

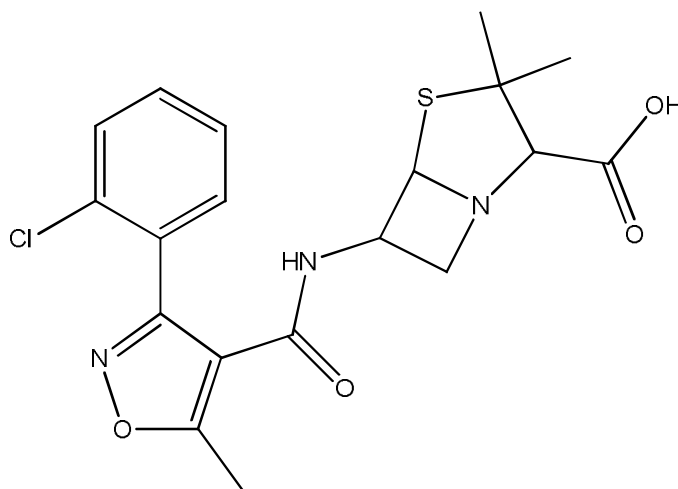


Fig.1 : Structure of Cloxacillin

2.2. Weight loss studies

The concentrations of inhibitor used for weight loss and electrochemical study were from $5 \times 10^{-4} \text{M}$ to $15 \times 10^{-4} \text{M}$. Mild steel specimens of size $1 \times 4 \text{ cm}^2$ were abraded with different emery papers and washed with acetone. The cleaned samples were then washed with double distilled water and finally dried and kept in the desiccator. The weight loss study was carried out at room temperature for three hours in $1 \text{M H}_2\text{SO}_4$. The inhibition efficiency (IE %) was determined by the following equation

$$\text{Inhibition Efficiency (IE \%)} = \frac{(W_0 - W_i)}{W_0} \times 100$$

Where W_0 & W_i are the weight loss values in the absence and presence of the inhibitor.

2.3. Electrochemical studies

Potentiodynamic polarization measurements were carried out in a conventional three electrode cylindrical glass cell, using CH electrochemical analyzer. The solution was deaerated for 20 minute before carryout the polarization studies. The working electrode was maintained at its corrosion potential for 10 min. until a steady state was obtained. The

mild steel surface was exposed to various concentrations of inhibitors in 100mL of 1M H₂SO₄ at room temperature. The inhibition efficiency (IE %) was calculated using the equation.

$$\text{Inhibition Efficiency (IE \%)} = (I_0 - I / I_0) \times 100$$

Where I_0 and I are the corrosion current density without and with the inhibitor respectively.

The potentiodynamic current–potential curves were recorded by changing the electrode potential automatically from –750mV to +150mV versus the open circuit potential. The corresponding corrosion current (I_{corr}) was recorded. Tafel plots were constructed by plotting E versus $\log I$. Corrosion Potential (E_{corr}), corrosion current density (I_{corr}) and cathodic and anodic slopes (β_c and β_a) were calculated according to known procedures.

Impedance measurements were carried out in the frequency range from 0.1 to 10000 Hz using amplitude of 20 mV and 10 mV peak to peak with an AC signal at the open–circuit potential. The impedance diagrams were plotted in the nyquist representation. Charge transfer resistance (R_{ct}) and double layer capacitance (C_{dl}) values were obtained from nyquist plot [25, 26]. The percentage inhibition efficiency was calculated from the equation

$$\text{Inhibition Efficiency (IE \%)} = (R_{\text{ct}} - R'_{\text{ct}} / R_{\text{ct}}) \times 100$$

Where R'_{ct} and R_{ct} are the corrosion current of mild steel with and without inhibitor respectively.

2.4. Hydrogen permeation studies

The hydrogen permeation study was carried out using an adaptation of modified Devanathan and Stachurski's , two compartment cell as described elsewhere [27]. Hydrogen permeation current was recorded in the absence and presence of inhibitors.

2.5. Surface morphology

The Scanning electron microscopy (SEM) was used to examine the specimen's surface which is immersed in blank and inhibitor solutions. Energy Dispersive spectrometer (EDS) is used to analyze the elements in the specimen. The following cases were examined in the SEM.

- I) Mild steel specimen immersed in 1M H₂SO₄

II) Mild steel specimens immersed in 1M H₂SO₄ containing 15x10⁻⁴ M inhibitor.

2.6. Diffuse reflectance spectroscopy

The surfaces of corroded and corrosion inhibited mild steel specimens were examined by diffuse reflectance studies in the region 200– 700 nm using U-3400 spectrometer [UV-VIS-NIR Spectrometer, Hitachi, Japan].

2.7. Theoretical calculations

Quantum calculations were carried using MOPAC 2000 program of CS Chemoffice packet program. The energy of highest occupied molecular orbital (HOMO), lowest unoccupied molecular orbital (LUMO), Dipole moment (μ), hardness, absolute softness and total energy of the molecule were calculated with the above given software package.

3. Results and discussion

3.1. Weight loss studies

The values of inhibition efficiency (IE %), corrosion rate (CR) and surface coverage (θ) calculated for Cloxacillin in 1M H₂SO₄ at different concentrations from the weight loss data are summarized in the table-1. It is obvious that inhibition efficiency enhances with increase in the inhibitor concentration. In addition the rate of corrosion has reduced with increase in inhibitor concentration. Maximum inhibition efficiency is obtained at 15x10⁻⁴ M concentrations of the inhibitor.

Table 1. Weight loss parameters for the corrosion of mild steel immersed in 1M H₂SO₄ in presence of different concentrations of Cloxacillin

Inhibitor Conc. (M)	Weight Loss (g)	Inhibition Efficiency	Corrosion Rate [mg cm ⁻² h ⁻¹]	Surface Coverage [θ]
Blank	0.0809	–	6.74	–
5x10 ⁻⁴	0.0235	70.95	1.95	0.7095
10x10 ⁻⁴	0.0178	77.99	1.48	0.7799
15x10 ⁻⁴	0.0088	89.12	0.73	0.8912

3.2. Potentiodynamic polarization studies

Polarization curves for mild steel in 1M H₂SO₄ containing different concentrations of inhibitor are given in figure-2. The values of corrosion potential (E_{corr}), corrosion current densities (I_{corr}), anodic tafel slope (β_a), cathodic tafel slope (β_c) surface coverage(θ) and inhibition efficiency (IE%) calculated using polarization curves are summarized in table-2.

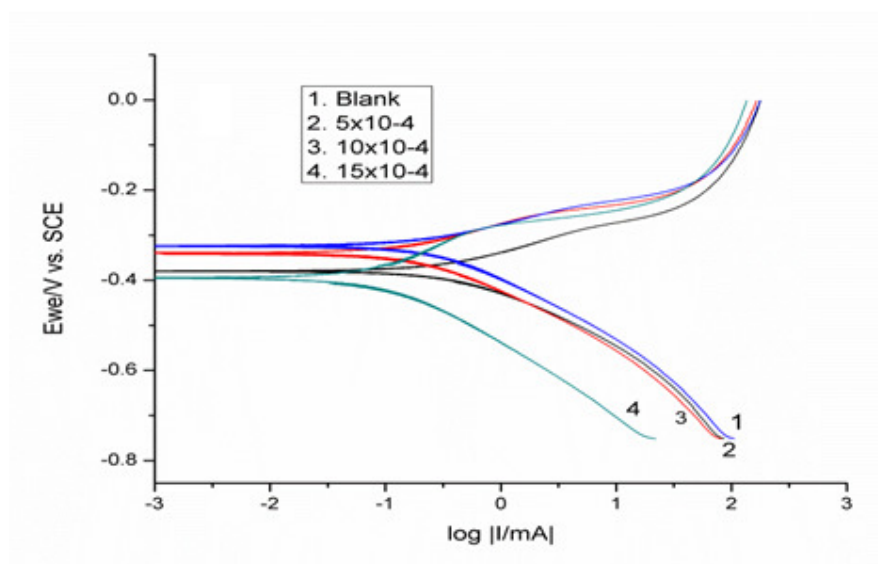


Fig. 2: Polarization curves of mild steel recorded in 1M H₂SO₄ in presence of different concentrations of Cloxacillin

According to the results, corrosion current (I_{corr}) value decreases with increase in the concentration of the inhibitor. The inhibition efficiency (IE %) and surface coverage (θ) increases with increase in inhibitor concentration. The maximum inhibition efficiency is achieved at 15×10^{-4} M concentration. Both β_a and β_c are reduced, but the values of β_c are decreased to a greater extent. This indicates that the compound behave as cathodic inhibitor.

Table 2: Potentiodynamic polarization parameters for mild steel immersed in 1M H₂SO₄ in the presence of different concentrations of cloxacillin.

Inhibitor	E _{corr}	I _{corr}	β _a	β _c	Inhibitor	Surface
Con.	[mV vs	[μA cm ⁻²]	[mV	[mV	efficiency	coverage
[M]	SCE]		dec ⁻¹]	dec ⁻¹]	[%]	[θ]
Blank	-376.12	548.57	82.9	135.3	-	-
5×10 ⁻⁴	-338.28	147.37	68.7	133.2	73.04	0.7313
10×10 ⁻⁴	-372.82	89.67	56.4	129.0	83.65	0.8365
15×10 ⁻⁴	-394.43	46.75	51.1	86.0	91.47	0.9147

3.3. Electrochemical impedance studies

The Nyquist representations of impedance performance of mild steel in 1M H₂SO₄ with and without addition of different concentrations of cloxacillin are shown in the figure-3. A large capacitive circle at higher frequency range is observed at all concentrations of the inhibitor. The higher frequency capacitive loop is due to the adsorption of inhibitor molecule [28].

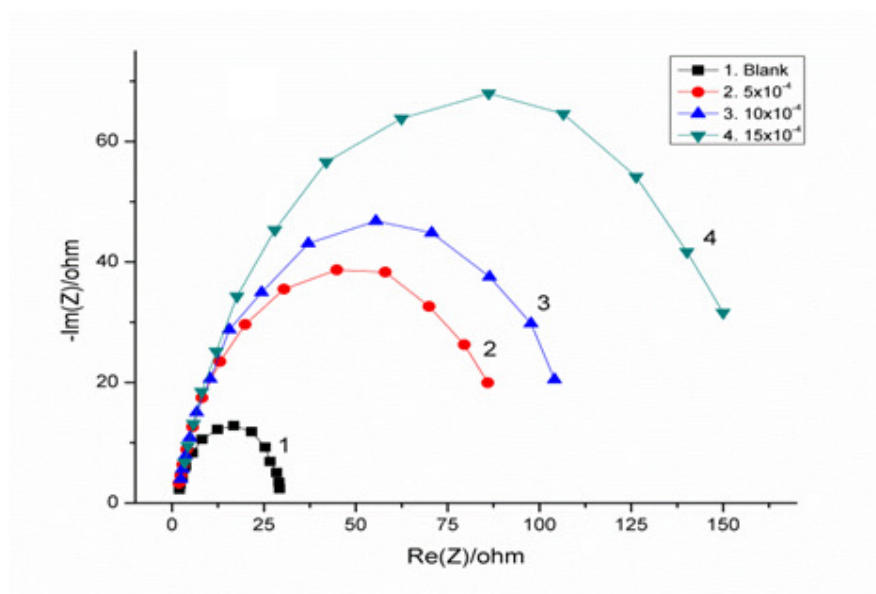


Fig. 3: Nyquist plot for mild steel immersed in 1M H₂SO₄ containing different concentrations of Cloxacillin

Values of charge transfer resistance (R_{ct}) and double layer capacitance (C_{dl}) derived from Nyquist plots are shown in table 3. The values of R_{ct} are found to increase with increase in concentration of inhibitor in 1M H₂SO₄. It is found that values of C_{dl} are fetched down by increasing concentrations of inhibitor in the acid. This can be ascribed to the well-built adsorption of the compounds on the metal surface.

Table 3: Electrochemical impedance parameters for mild steel immersed in 1M H₂SO₄ in the presence and absence of different concentrations of cloxacillin.

Inhibitor	R_{ct}	C_{dl}	Inhibition	Surface
Con. [M]	[$\Omega \text{ cm}^2$]	[F cm^{-2}]	efficiency [%]	coverage[θ]
Blank	28.1	0.489	–	–
5×10^{-4}	110.6	0.283	74.59	0.7459
10×10^{-4}	160.0	0.195	82.0	0.8200
15×10^{-4}	252.84	0.078	88.89	0.8889

3.4. UV spectral reflectance studies

The reflectance curves for polished specimen, specimen dipped in 1M H₂SO₄ and various concentrations of inhibitor are given in the figure.4. The percentage of reflectance is highest for polished mild steel and it steadily reduces for the specimen dipped in 1M H₂SO₄ solution. This observation discloses that the change in surface feature is due to the corrosion of mild steel in acid. The reflectance percentage of steel in the presence of inhibitor is higher than steel as immersed in blank. This validates that the surface property of steel are not altered further due to the formation of film on the metal. The reflectance percentage decreases with increase in thickness of the inhibitor film formed on metal surface. Similar observation has been made by Madhavan et al [29].

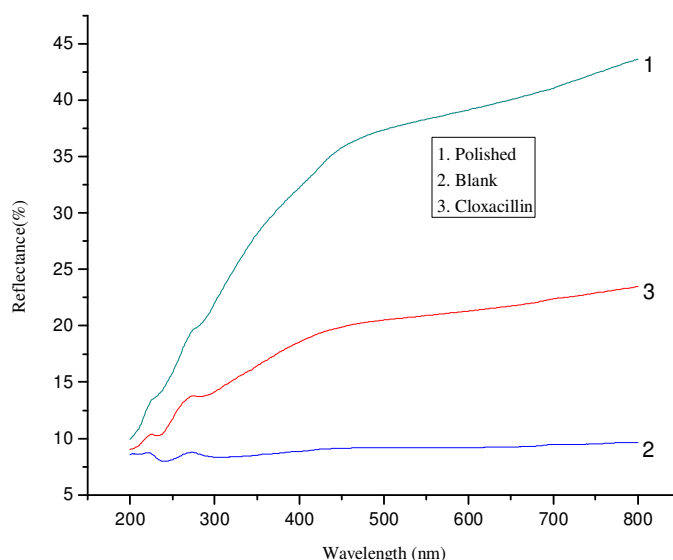


Fig. 4: UV Reflectance curves of mild steel in 1M H₂SO₄ solution with 15x10⁻⁴M concentration of the inhibitor.

3.5. Adsorption isotherm and thermodynamic parameters

The inhibitive action of inhibitor in highly aggressive media is due to its adsorption on the metal surface. The degree of surface Coverage (θ) for different concentrations of inhibitor in 1M H₂SO₄ has been calculated from weight loss, Polarization and Electrochemical Impedance studies. The acquired data was tested graphically for fitting suitable isotherm [30–32]. Almost a straight line was obtained by plotting $\log (C/\theta)$ Vs

log C as shown in Figure–5, which proves that the adsorption of these compounds on steel surface obeys Langmuir adsorption isotherm.

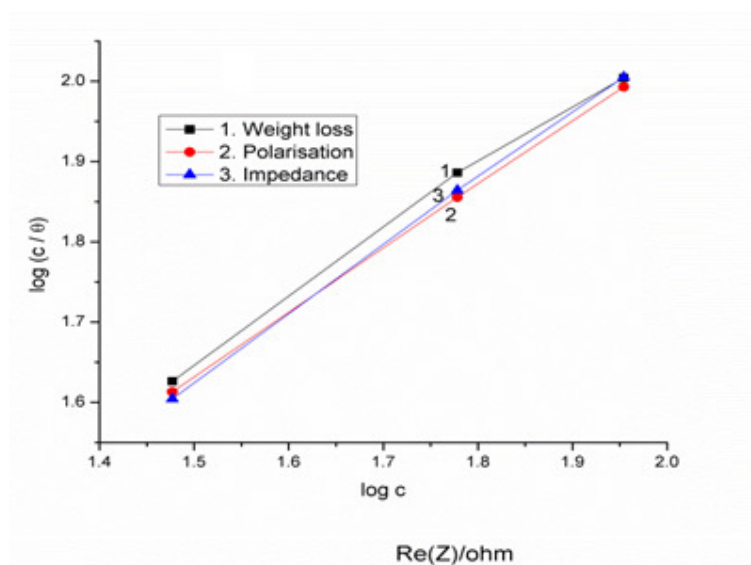


Fig. 5: Langmuir's adsorption isotherm plots for the adsorption Cloxacillin in 1M H₂SO₄ on the surface of mild steel.

The Langmuir isotherm for the adsorbed layers is given by the equation [33],

$$C_{inh}/\theta = 1/K_{ads} + C_{inh}$$

Where K_{ads} is the equilibrium constant of the adsorption/desorption process. Adsorption equilibrium constant [K_{ads}] and free energy of adsorption [ΔG^0_{ads}] were calculated using the equation [34]

$$K_{ads} = 1/C_{inh} \times \theta/(1-\theta)$$

$$\Delta G^0_{ads} = -2.303RT \log [55.5K_{ads}]$$

Where 55.5 is the molar concentration of water in solution [35]. R is the gas constant, T is the temperature. The values of adsorption equilibrium constant [K_{ads}] and free energy of adsorption [ΔG^0_{ads}] are given in table–4. The negative values of [ΔG^0_{ads}] pointed out that adsorption of inhibitors is spontaneous process. It is reported that values of [ΔG^0_{ads}] is of order 20 kJmol⁻¹ or lower indicates a physisorption, those of order of

-40 kJmol^{-1} or higher involve charge sharing or transfer from the inhibitor to the metal surface species a chemisorptions [36–38]. The values of free energy of adsorption $[\Delta G^0_{\text{ads}}]$ in our experiment lies in the range -28 to -32 kJmol^{-1} , demonstrating that the adsorption is not a simple physisorption, but it may involve some other interactions [39].

Table 4: Gibbs free energy parameters and adsorption equilibrium constant $[K]$ of inhibitor at various temperatures evaluated by weight loss method.

Temperature (K)	K_{ads}	$-\Delta G^0_{\text{ads}} (\text{kJmol}^{-1})$
313	954	28.30
323	1191	29.80
333	1372	31.11

3.6. Hydrogen permeation measurements

Hydrogen permeation currents are recorded in H_2SO_4 in the absence and presence of inhibitor. This study has been taken up with a plan of selecting the inhibitor with a view to their efficacy on the reduction of hydrogen uptake [40]. The values of permeation current with respect to time are given in table–5. Figure 6 shows the variation of permeation current vs time for mild steel in 1M H_2SO_4 in the presence of Cloxacillin.

Table 5: Values of permeation current for mild steel in 1M H₂SO₄ and in presence of inhibitors with respect to change in time

Time (min.)	Permeation Current (μ A)	
	1M H ₂ SO ₄	Cloxacillin
0	10.8	2.9
5	11.2	4.2
10	12.0	4.8
15	12.3	5.3
20	12.9	5.5
25	12.9	5.5
30	12.9	5.5
35	12.9	5.5
40	12.9	5.5

The Cloxacillin brings down the permeation current to the extent of 50%. The corrosion inhibition efficiency of the compound in 1M H₂SO₄ follows the same order. Thus a definite correlation exists between the corrosion inhibition efficiency and the extent of reduction in the permeation current of the compound. It is a recognized fact that higher β_c value for an inhibiting compound, the lesser is the corrosion and hydrogen ingress on the metal. An increase in the β_c value, leads to increase in the energy barrier for proton discharge and decrease in the evolution of hydrogen. This in turn leads to lower permeation of hydrogen through the metal.

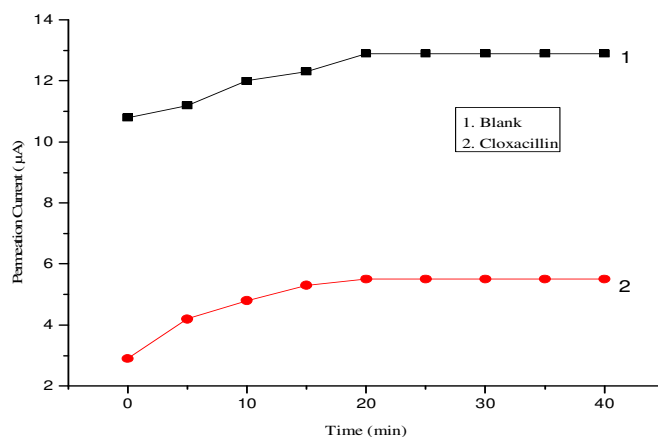


Fig.6: Hydrogen permeation Vs Time curves for mild steel immersed in 1M H₂SO₄ and 15x10⁻⁴ M concentration of inhibitor

3.7. Scanning electron microscopic studies

SEM images for mild steel surface immersed in 1M H₂SO₄ solutions for 3 hrs in the presence and absence of cloxacillin are displayed in Figure 7 (A & B). The surface of mild steel is greatly damaged in the absence of the inhibitor (Figure 7A). SEM image of inhibited mild steel specimen (Figure 7B) explains that fine protective adsorbed film is formed on the specimen's surface, which reduces the rate of corrosion, being accountable for the inhibition.

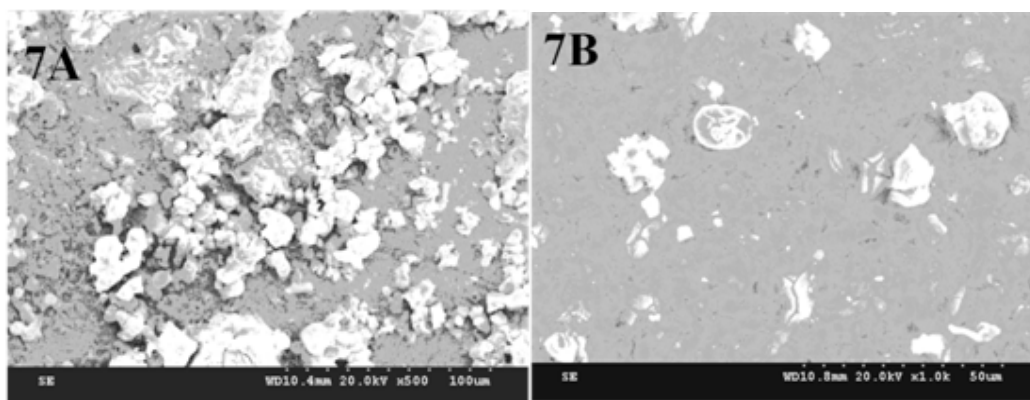


Fig. 7; SEM images of mild steel [7A] immersed in 1M H₂SO₄ for 3h, [7B] cloxacillin

3.8. Mechanism of corrosion inhibition

The adsorption of cloxacillin on the mild steel surface is found to be majorly physical in nature. Physical adsorption is a process of electrostatic attraction between charged species in the solution and the metal surface. If the metal surface is positively charged, the adsorption of negatively charged species is facilitated. Positively charged species can also adsorb on the positively charged metal surface with the help of negatively charged intermediate, which adsorb first on the positively charged metal surface and allows positively charged species to adsorb on it.

Thus the adsorption of Cloxacillin may take place in two different ways as

- (i) The protonated cloxacillin and ampicillin in acid solution may adsorb electrostatically to the anion covered mild steel surface through their protonated form.
- (ii) The inhibitors may compete with acid anions for the sites at the water covered surface and adsorb by donating electrons to the mild steel surface [41, 42].

3.9. Quantum chemical calculations

Quantum chemical calculations were carried out to investigate the adsorption and inhibition mechanism of the inhibitors. Figure 8 shows the optimized structure of Cloxacillin. The values of calculated quantum chemical parameters i.e. E_{HOMO} (highest occupied molecular orbital), E_{LUMO} (lowest unoccupied molecular orbital), ΔE (energy gap), μ (dipole moment), σ (softness) etc. are summarized in table-6.

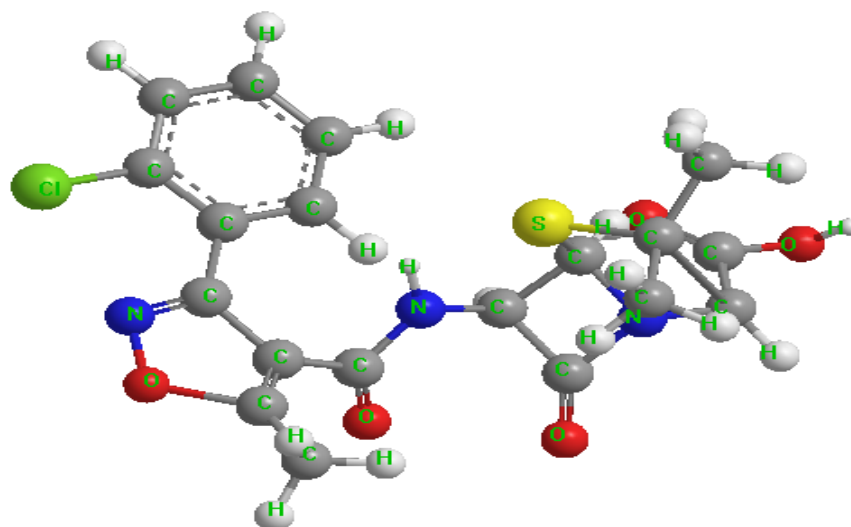


Fig. 8: Optimized structure of cloxacillin

E_{HOMO} is associated with the electron-donating ability of the molecule. Several researchers have shown that the adsorption of an inhibitor on metal surface can occur on the basis of donor-acceptor interactions between the π -electrons of heterocyclic atoms and the vacant d-orbitals of the metal surface atoms [43–45]. A high value of E_{HOMO} indicates a tendency of a molecule to donate electrons to acceptor molecules with low energy empty molecular orbital. Increasing values of E_{HOMO} facilitates the adsorption and increases the inhibition efficiency by influencing the transport process through the adsorbed layer [46]. E_{LUMO} indicates the ability of the molecule to accept the electrons, hence these are acceptor states. The lower the value of E_{LUMO} , the more probable is that the molecule can accept electrons and increase the inhibition efficiency. Regarding ΔE ($E_{\text{LUMO}} - E_{\text{HOMO}}$) lower values of energy difference will cause higher inhibition efficiency because energy to release electron from last occupied orbital will be low. When dipole moment is concerned higher values of μ , will favours a strong interaction of inhibitor molecule with the metal surface [47].

Other indicators are absolute electro negativity (χ), absolute hardness (η). Absolute electro negativity is a chemical property that describes the ability of a molecule to attract electron towards itself in a covalent bond. Absolute hardness is measured by the energy gap between E_{HOMO} and E_{LUMO} . Absolute softness σ is the reciprocal of the hardness. χ , η , σ are calculated using the energies of HOMO and LUMO orbital's of the inhibitor molecules are related to the ionization potential (I), electron affinity (A) by the following relations

$$\chi = I + A / 2, \eta = I - A / 2, \sigma = 2 / I - A$$

$$\text{Where } I = -E_{\text{HOMO}}, A = -E_{\text{LUMO}}$$

The results deduced indicate that the electron flow will happen from the molecule with low electro negativity towards that of higher value until the chemical potentials are same. In our studies the best inhibition effect is shown by cloxacillin with low electro negativity.

The higher value of dipole moment and lower total energy for cloxacillin indicates the strong interaction of inhibitor with metal that leading to improved adsorption. The halogen atom exerts +M effect on cloxacillin, leads to enhanced corrosion inhibition.

From figure 9 it can be observed that the energy highly occupied molecular orbital's (HOMO) are localized on hetero atoms for cloxacillin.

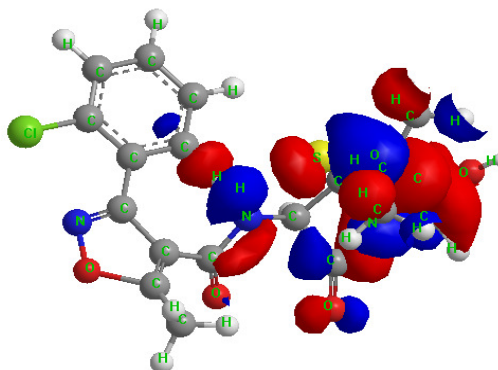


Fig.9: The Highest occupied molecular orbital of Cloxacillin

From Figure 10 it is observed that lowest unoccupied molecular orbital's (LUMO) of Cloxacillin, which is responsible for its lower inhibition efficiency than cloxacillin.

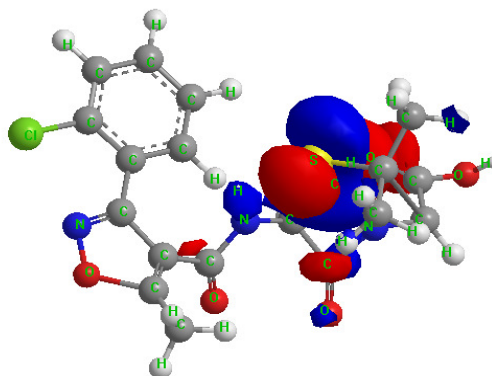


Fig. 10: The lowest unoccupied molecular orbital of Cloxacillin

4. Conclusions

1. The use of antibiotic as corrosion inhibitor in 1M H₂SO₄ was thoroughly studied using weight loss, potentiodynamic polarization, impedance measurements and hydrogen permeation studies.
2. The adsorption of inhibitor on mild steel surface follows Langmuir adsorption isotherm. The adsorption of compound on steel surface is further confirmed by diffuse reflectance spectra and SEM images.
3. The quantum mechanical studies substantiate the performance of antibiotic as excellent corrosion inhibitors for mild steel in 1M H₂SO₄.

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